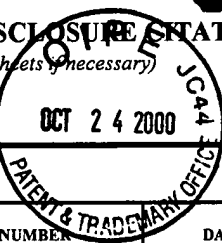


# INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

OCT 24 2000



Docket Number (Optional)

13521(ARC920000067U)

Application Number

09/634,171

Applicant(s)

Emmanuel I. Cooper et al.

Filing Date

August 9, 2000

Group Art Unit

## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
JSL		2,654,703	10/06/53	Brown			
JSL		4,014,759	03/29/77	McMullen et al.			
JSL		4,053,373	10/11/77	McMullen et al.			
JSL		4,208,254	06/17/80	Mitsumoto et al.			
JSL		4,306,908	12/22/81	Takayama et al.			
JSL		4,756,816	07/12/88	Liao et al.			
JSL		4,925,502	05/15/90	Yamagishi et al.			
JSL		4,933,026	06/12/90	Rawlings et al.			
JSL		5,372,698	12/13/94	Liao			
JSL		5,582,927	12/10/96	Andricacos et al.			
JSL		5,587,026	12/24/96	Iwasaki et al.			

## FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
JSL		JP 6036929 A2 (Abstract only)	02/10/94	Japan				
JSL		JP 4229607 A2 (Abstract only)	08/19/92	Japan				
JSL		JP 2107737 A2 (Abstract only)	04/19/90	Japan				

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

JSL		Chen et al., "Soft-Magnetic Properties of Fe-Co-B Thin films For Ultra-High-Frequency Applications, J. App. Phys. 87, No. 9, 5858-5860(2000).
JSL		Rehim et al. "Electroplating of CoFe Alloys From Aqueous Acetate Baths", Trans. IMF, 78, No. 1, 41-43(2000).

EXAMINER

John P. Sheehan

DATE CONSIDERED

9-7-2001

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

# INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

13521(ARC90000067US)

Application Number

09/634,171

Applicant(s)

Emmanuel L. Cooper et al.

Filing Date

August 9, 2000

Group Art Unit

\*EXAMINER  
INITIAL

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

Kakuno et al. "Structure, Composition, and Morphology of Electrodeposited Co<sub>x</sub>Fe<sub>1-x</sub> Alloys", J. Electrochem. Soc. 144, No. 9, 3222-3226(1997).

Herreros et al., "Preparation of Fe-Co-P Amorphous Alloys By Electrodeposition", J. Non-Crystalline Solids, 201, 102-109(1996).

Arcos et al., "Direct and Pulse Current Electrodeposition of Ternary CoFeX, CoNiX and Ni FeX Thin Film Alloys", Electrochemical Soc. Proc., 95, No. 18, 562-569.

Liu et al., "Electrodeposition of soft, high moment Co-Fe-Ni Thin Films", J. Appl. Phys., 87, No. 9, 5410-5412(2000).

EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.